

Supporting information

Pressure-Shortened Delayed Fluorescence Lifetime of Solid-state Thermally Activated Delayed Fluorescent 4CzIPN: the Structure Evolution

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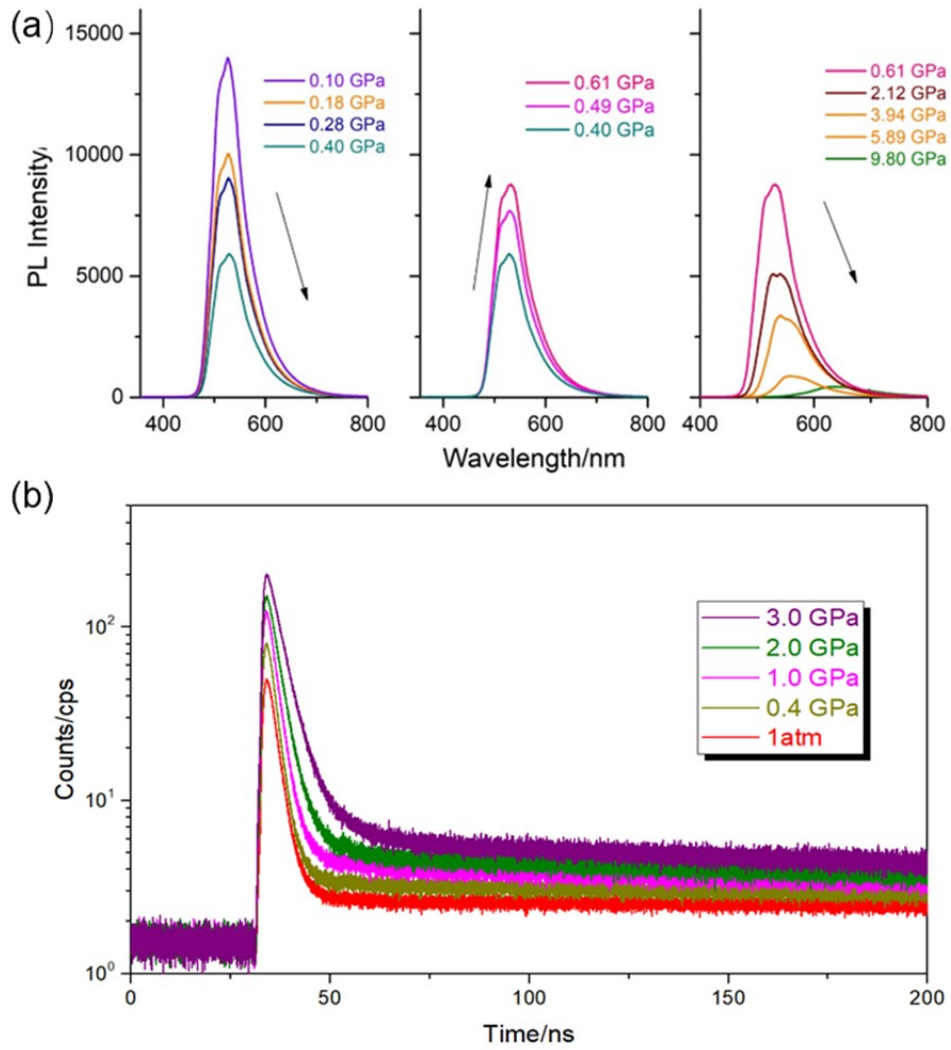


Fig. S1 (a) The PL spectra of 4CzIPN in the range of pressures from 0.1 to 9.8 GPa. (b) The change of prompt fluorescence lifetime with increasing pressure.

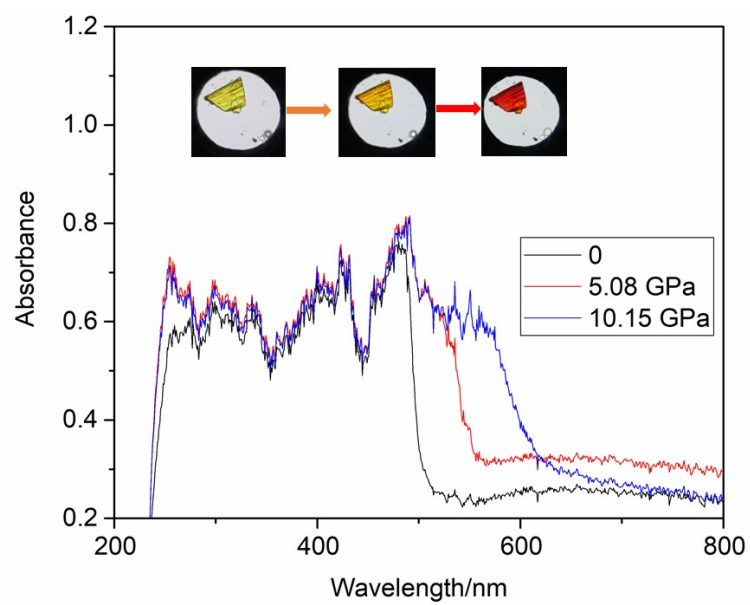


Fig. S2 the UV-vis absorption spectrum of 4CzIPN under high pressure.

Table S 1 The FWHM of the emission bands under different pressure.

Pressure/GP	0.1	1.1	2.1	3.1	4.3	5.3	6.9	8.7	9.8
a									
FWHM/nm	70.20	77.09	78.15	79.79	80.23	84.40	96.17	112.22	119.36

Table S 2 The short PL lifetime under different pressure.

Pressure/GP	0.1	1.0	2.0	3.0	4.0	5.0	6.0	7.0	8.0	9.0	10.0
a											
Lifetime/ns	2.75	2.76	3.13	4.02	4.94	6.23	11.76	10.42	8.97	6.22	2.69

Table S 3 The long PL lifetime under different pressure.

Pressure/GPa	0.1	0.4	1.0	1.5	2.0
Lifetime/μs	1.04	0.65	0.47	0.43	0.4

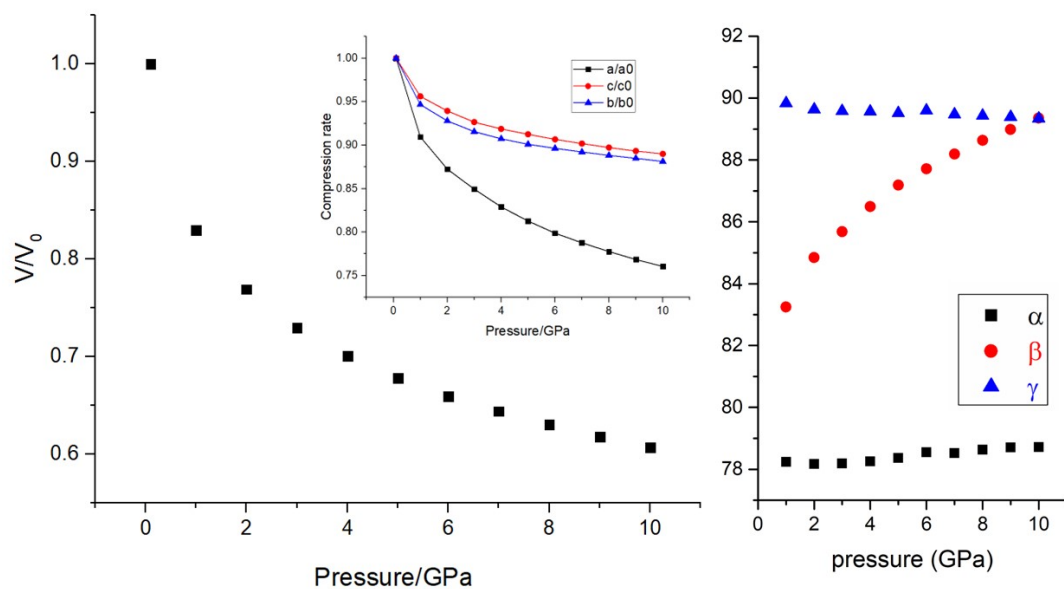


Fig. S3 (a) Compression of the unit cell volume of 4CzIPN with respect to pressure. The inset shows the compression rate of lattice constants under different pressure. (b) the change of angle α , β , γ with pressure.

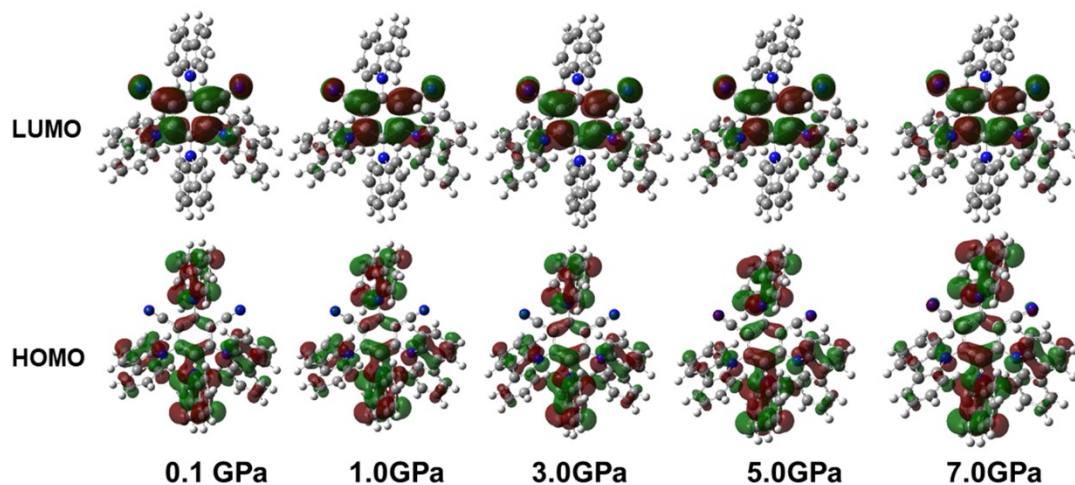


Fig. S4 The HOMO and LUMO of 4CzIPN molecule under different pressure.

Table S 4 The energy level of S₁ and T₁, Singlet-Triplet Energy Difference (ΔE_{ST}) under different pressure

Pressure/GP	0.1	1.0	2.0	3.0	4.0	5.0	6.0	7.0
a								
S1/eV	2.520	2.578	2.613	2.633	2.656	2.675	2.697	2.711
T1/eV	2.361	2.397	2.419	2.430	2.444	2.458	2.473	2.481
ΔE_{ST}	0.159	0.181	0.194	0.203	0.212	0.217	0.224	0.230

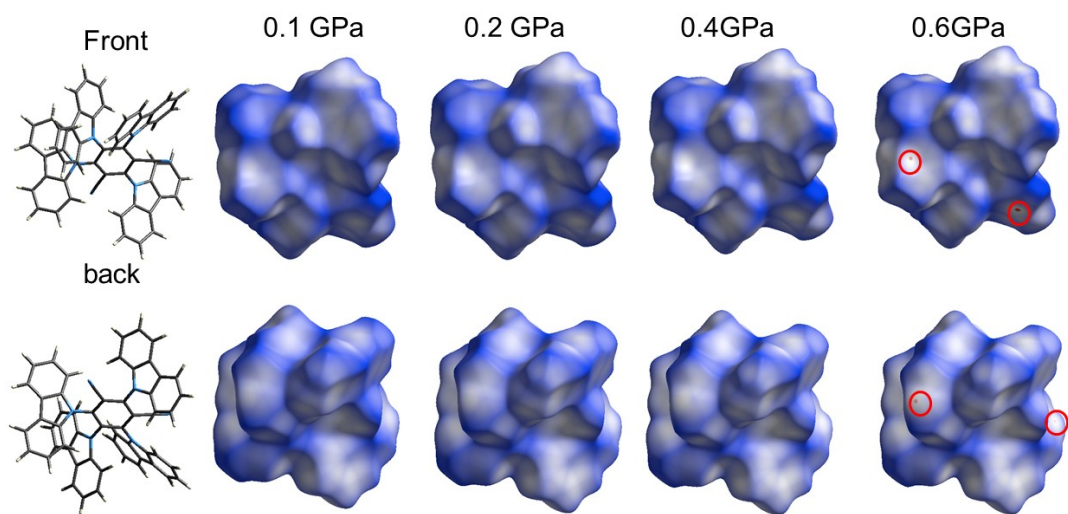


Fig. S5 Hirshfeld Surface for the Calculated Structure at 0.1, 0.2, 0.4, and 0.6GPa Mapped with a d_{norm} Distance.

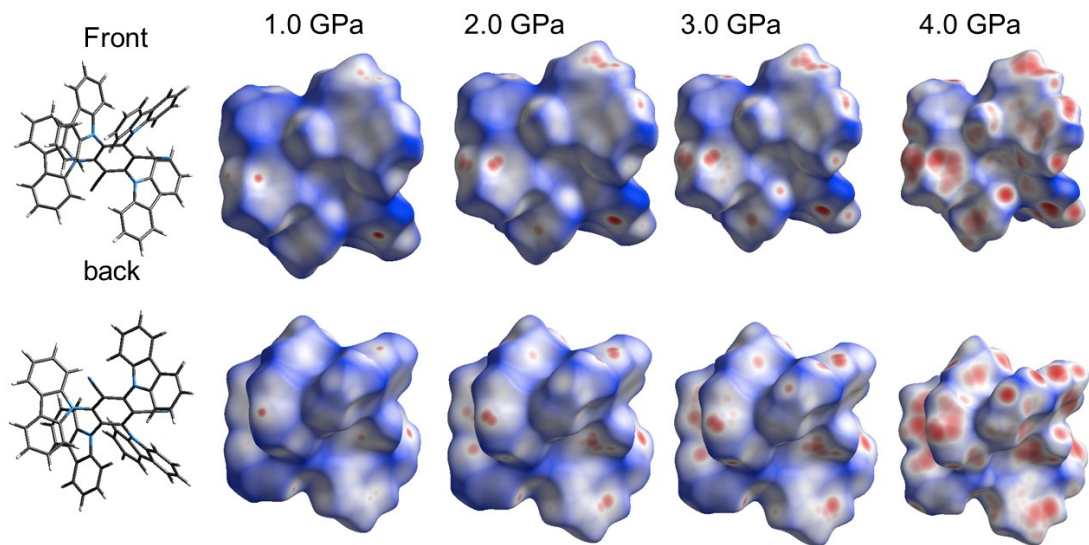


Fig. S6 Hirshfeld Surface for the Calculated Structure at 1.0, 2.0, 3.0, and 4.0 GPa Mapped with a d_{norm} Distance.

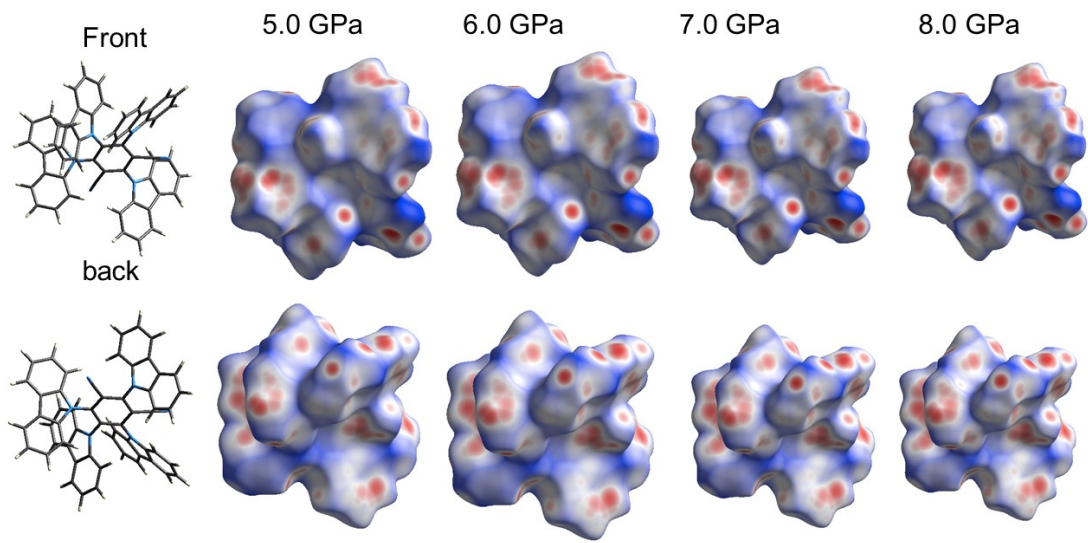


Fig. S7 Hirshfeld Surface for the Calculated Structure at 5.0, 6.0, 7.0, and 8.0 GPa Mapped with a d_{norm} Distance

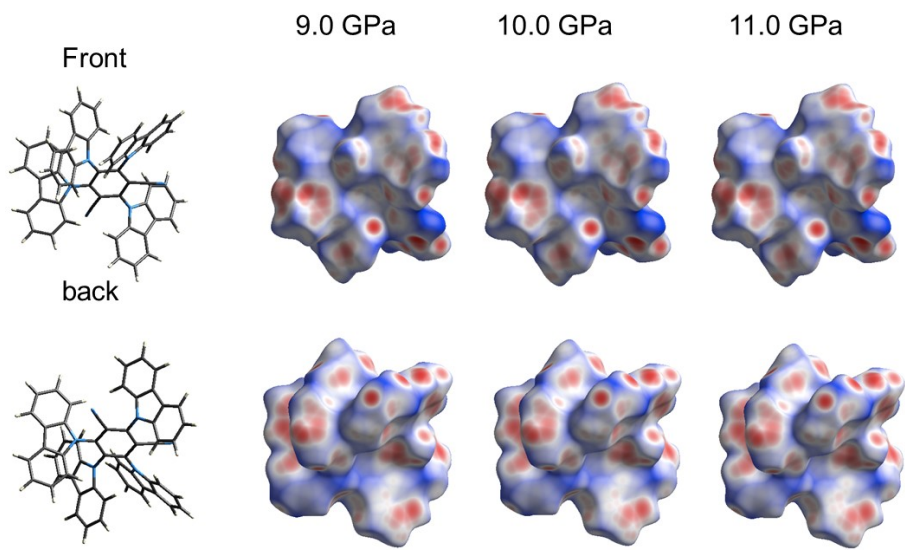


Fig. S8 Hirshfeld Surface for the Calculated Structure at 9.0, 10.0 and 11.0 GPa Mapped with a d_{norm} Distance

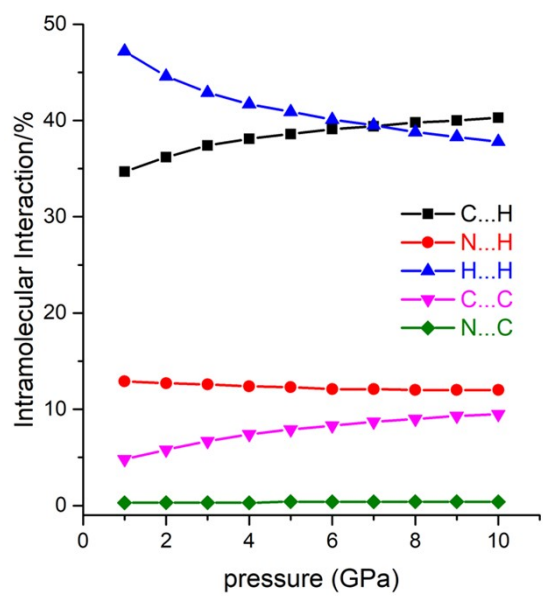


Fig. S9 Contribution rate of different interactions to the Hirshfeld surface area versus pressure.